MEMs Parallel Plate Rheometer for Oscillatory Shear Micro **Rheology Measurements**

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10

 10^{2}

ω [rad/s]

oligomer

10

Emulsion in µchannel

Agarose shear gel

Colloidal Suspension

10 Microns

Motivation

- Novel viscoelastic materials Micro scale structure
- Confinement deforms structure Alters rheology
- Characterization difficult
 - Small sample volumes
- Particle micro rheology does not probe entire micro structure
- Thin film measurements only elastic modulus

MEMs Parallel Plate Rheometer



- 1 mm² nano-positioner applies sinusoidal strain
 - Thermal Actuator
 - 0.1%< γ <25%
- •O(1) um gap set with thin film
- Strain applied to the entire fluid body
- Optical observation
- Storage and loss moduli at 0.5 Hz< f <500 Hz
- •Uses less than 10 nL of fluid

National Institute of Standards and Technology

Mechanical Modeling



Viscous Fluid Calibration



- Surface tension affects amplitude
- Model predicts general behavior
- •±25% device error on viscosity above 1 Hz
- •±150 Pa error on elastic modulus above 1 Hz

PDMS Thin Films



- Consistent results for viscous fluids and viscoelastic thin films
- Large frequency domain,~3 decades, with O(1) um gap sizes

5um Gap, High MW Redesign of device should PIB in 500 g/mol PIB improve accuracy and sensitivity

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